

Open-Source Radiation Hardening Simulator: Design, Implementation, and Applications

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Abstract—This paper presents the design, implementation, and applications of an open-source radiation hardening simulator developed using Xschem and Ngspice. The simulator aims to address the challenges of simulating radiation effects on electronic circuits by providing a comprehensive library and user-friendly interface. The project integrates core modules for radiation effect simulation, including Single Event Effects (SEE), along with thorough documentation and examples to support users in their research and development efforts. Preliminary tests demonstrate the simulator’s accuracy in modeling radiation effects, offering significant potential for future research and development.

Index Terms—radiation hardening, electronic circuits, fault injection, simulation, Xschem, NGSpice

I. INTRODUCTION

The accurate simulation of radiation effects on electronic circuits is a key step in the development of robust systems in space, nuclear, and other radiation-prone environments. Radiation can induce a variety of faults and errors in electronic components, leading to system failures. Thus, understanding and mitigating these effects is essential for ensuring the reliability of electronic systems [1], [2].

Natural radiation is known to be a significant source of microelectronics failure, impacting various applications from aerospace to ground-level electronics. To predict the reliability of these devices, tools like MC-ORACLE and RADSPICE have been developed to simulate the effects of radiation on microelectronic materials [1], [2].

In this paper, we introduce an open-source radiation hardening simulator that leverages Xschem and NGSpice. This tool is designed to simulate and analyze the effects of radiation on electronic circuits, and aims to facilitate the development and testing of radiation-hardened designs. Our approach includes simulating Single Event Effects (SEE) using advanced models such as adaptive double exponential current sources to improve the accuracy of simulations [3].

The paper is structured as follows: Section II provides an overview of the project, including its background, objectives, and scope. Section III details the methodology and implementation, describing the integration of Xschem, NGSpice, and custom-developed modules. Section IV presents the testing, results, and discussion, highlighting the system’s performance and the challenges encountered. Finally, Section V concludes the paper and outlines future work.

II. PROJECT OVERVIEW

This section provides an overview of the project, including structure, background, objectives, and scope.

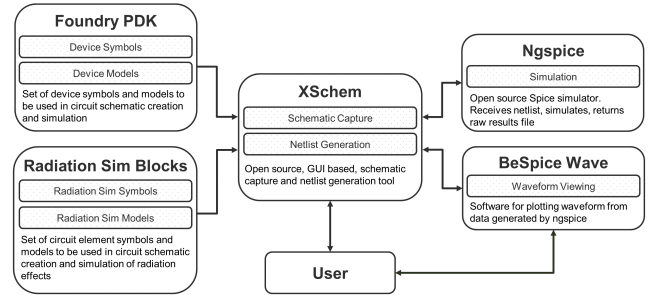


Fig. 1. Interaction Diagram. This figure shows how different components of the project interact with each other.

A. Structure

To facilitate easy schematic creation and simulation, we’ve chosen to use an open source program called Xschem. Xschem provides a GUI interface for drawing circuits, generating netlists, running simulations, and viewing waveforms. We’ve created a set of radiation simulation blocks that can be imported into Xschem as components. These components can then be included in schematics and simulated. Once a schematic is created, Xschem generates a netlist, sends the netlist to ngspice to simulate, receives the results from ngspice, and finally send the results to an external waveform viewer (in this case we are using BeSpice Wave). This structure is detailed in Fig. 1

B. Background

Single-Event Effects (SEEs) are some of the most commonly simulated radiation effects. One single-event effect of interest are transients resulting from photocurrent generation. When a radiation particle passes through silicon, it generates electron hole pairs along the length of the radiation track. In most cases, there is no strong electric field to separate these charges and the electron hole pairs recombine randomly. If, however, the electron hole pairs are generated in the proximity of a strong electric field, such as a reverse biased PN junction, the electrons and holes can be separated before recombination can occur. These charges are swept out of the junction which creates a photocurrent in the circuit. This photocurrent then

generates transients in the circuit. These transients are one of many single-event effects. Fig. 2 depicts a radiation event taking place in a CMOS inverter.

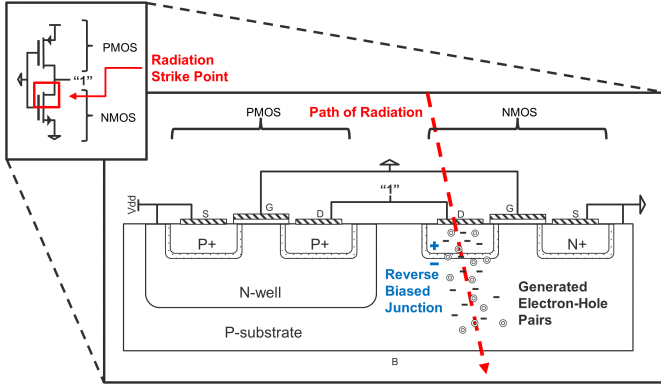


Fig. 2. Radiation event in a CMOS Inverter. In the above configuration, the drain of the NMOS transistor is held in a reverse bias condition. When radiation strikes the aforementioned drain region, electron-hole pairs are generated along the radiation track. A photocurrent is then generated due to the reverse bias condition, thus creating voltage transients.

C. Project Scope and Objectives

There are multiple existing Radiation-Hardened SPICE simulators; however, these simulators are not open-sourced, limiting their accessibility to users who can afford to purchase these software environments. The primary objective of this project is to develop an open-source, radiation-effects SPICE simulator that is both user-friendly and accurate in its modeling capabilities. This was accomplished by researching various contemporary methods and modules for modeling radiation effects in circuits and integrating them into existing open-source SPICE programs, specifically XSchem for the front-end and NGSpice for the back-end. Additionally, we ensured that the interface for applying these methods was intuitive, facilitating their integration into users' design flows.

III. METHODOLOGY AND IMPLEMENTATION

Our simulator presents a user-friendly and intuitive experience to the user. To effectuate this, we implement each radiation effect as a block that can be placed and connected to other components in XSchem. A description of each block is as follows:

A. Single Event Effect [SEE] Simulation

1) *Double Exponential Current Source*: A simple way to model the photo-current generated in a reverse biased pn junction due to a radiation strike is with a double exponential current source. This method has existed for decades and is widely used. Fig. 3 depicts a double exponential waveform.

The equations that govern the behavior of such a double exponential current source are given in equations (1) and (2)

$$I_{\text{peak}} = \frac{Q_{\text{tot}}}{[(t_f - t_r) - \tau_r + \tau_f]} \quad (1)$$

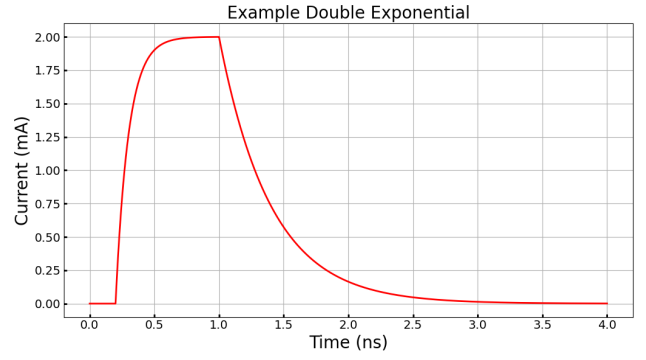


Fig. 3. Double exponential waveform

$$I = \begin{cases} 0, & t < t_r \\ I_{\text{peak}} \left(1 - e^{-\frac{(t-t_r)}{\tau_r}} \right), & t_r \leq t < t_f \\ I_{\text{peak}} \left(e^{-\frac{(t-t_f)}{\tau_f}} - e^{-\frac{(t-t_r)}{\tau_r}} \right), & t_f > t \end{cases} \quad (2)$$

t_r - The simulation time at which charge injection begins

t_f - The simulation time at which charge injection halts

τ_r - The rise time constant of I_{SRC}

τ_f - The fall time constant of I_{SRC}

Q_{tot} - The total charge to be injected into the node

2) *Dual Double Exponential Current Source*: A limitation of the simple double exponential current source is that it can be inaccurate in some scenarios. It has been found that a more realistic photo-current waveform consists of an initial peak followed by a plateau region caused by limitations of PMOS drive current in CMOS circuitry, and a final drop off. This waveform can be represented by adding two double exponential current sources together resulting in a dual double exponential current source. Fig. 4 depicts a dual double exponential waveform [4].

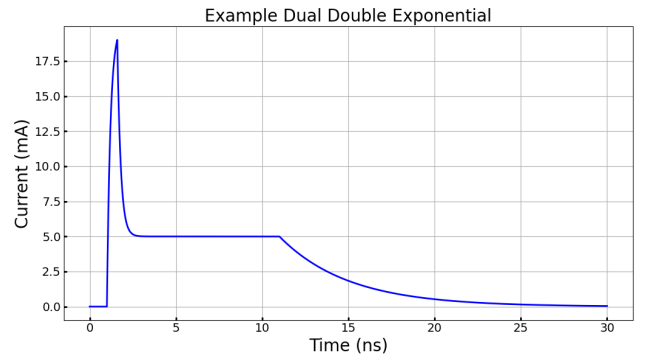


Fig. 4. Dual double exponential waveform

3) *Adaptive Double Exponential Current Source*: A problem that arises when using either the double or dual double exponential current models is that these models can produce

unrealistic node voltages. If, for example, a double or dual double exponential current source is placed from the drain to the body node of a reverse biased NMOS transistor, when the current source is activated, the drain node voltage can be pulled below the ground node voltage. This means that the NMOS transistor is no longer held in reverse bias and no current should be flowing.

The adaptive double exponential current source solves this problem by adjusting the drive current proportional to the voltage across the reverse bias PN junction of the transistor for which a radiation strike is being simulated for. This adjustment allows the node voltage to drop to near zero and remain at this level until the radiation induced current spike is complete. The resulting current waveform closely resembles that of a dual double exponential current source. Fig. 5 shows how the adaptive double exponential current source is constructed.

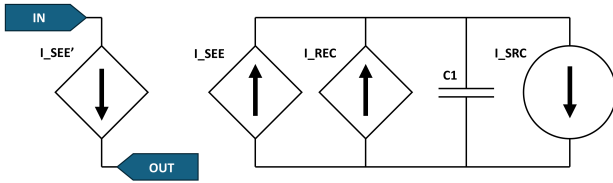


Fig. 5. Overview of adaptive double exponential current source model [5]

The following equations define the behavior of the adaptive model:

$$I_{SEE} = Q(C1) \cdot (V(IN) - V(OUT)) \cdot k \quad (3)$$

I_{SEE} (The observed current due to single event effects) is a function of the total charge stored in the capacitor, the voltage across the adaptive current source, and an adjustment constant k .

$$I_{REC} = recomb_adj \cdot Q(C1) \cdot k \quad (4)$$

I_{REC} (The current due to electron-hole pair recombination effects) is a function of an adjustment parameter $recomb_adj$, the total charge on the capacitor, and a second adjustment constant k . Note, this k is the same k as presented in Equation 3.

$$I'_{SEE} = I(I_{SEE}) \quad (5)$$

I'_{SEE} is a current mirror of I_{SEE} . This allows for the calculation portion of the circuit to be separated from outside influence.

Lastly, I_{SRC} is the standard double exponential current source given by equations (1) and (2).

A description the additional parameters in the adaptive current source is as follows:

- k - A constant for proportionally adjusting the drive strength of B_{SEE} and B_{REC}
- $recomb_adj$ - A constant for proportionally adjusting the drive strength of B_{REC}

4) *Usage*: To simulate a single event effect on a PMOS transistor, a single event effect simulation block must be placed with the input of the block connected to the body node of the PMOS transistor and the output of the block connected to the drain node of the PMOS transistor as shown in Fig. ??.

To simulate a single event effect on an NMOS transistor, a single event effect simulation block must be placed with the input of the block connected to the drain node of the NMOS transistor and the output of the block connected to the body node of the NMOS transistor. Both of these configurations are demonstrated in Fig. ?. The reason behind these configuration restraints is beyond the scope of this paper.

B. Other Radiation Effect Simulations

1) *Rail Span Collapse Voltage Source*: A radiation induced phenomenon known as rail span collapse is often observed in complex circuits. Rail span collapse is characterized by the voltage between the positive and negative voltage rail collapsing due to excess current draw. This voltage collapse can result in severe problems, especially in circuitry with sequential logic.

One example where rail span collapse can cause issues is in an SRAM circuit. When an SRAM is irradiated, each time a reverse biased MOSFET is struck a photo-current is generated in the junction. These photo-currents can be compounded together which can result in more current being drawn than the voltage rails can supply. This reduction in voltage difference between the positive and negative power rails can then cause the SRAM to become more susceptible to upsets, or lose its saved state all together.

We've chosen to model the voltage drop due to excessive current draw as a logistic function. This logistic function outputs a voltage drop for a given current draw as input. Fig. 6 shows an example plot of this model. The function is tuned such that significant voltage drop begins to occur once a current of 3mA is exceeded. When more than about 5mA is drawn the voltage source can no longer sustain the load and the voltage drop is near 1.8 volts. Given that the voltage source in this example has a nominal voltage of 1.8 volts, this means that there is near zero voltage between the positive and negative rails after 5mA.

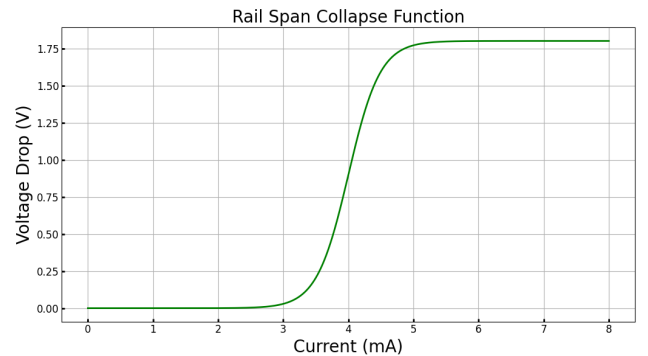


Fig. 6. Rail span collapse function.

The following equations define the behavior of the rail span collapse model:

$$V(I) = V_{nominal} - \frac{V_{nominal}}{1 + e^{-k(I-I_0)}} \quad (6)$$

Where I_0 , the inflection point of the logistic function, is defined as:

$$I_0 = I_{limit} - \frac{\ln\left(\frac{V_{limit}}{V_{initial}-V_{limit}}\right)}{k} \quad (7)$$

A detailed description of each parameter in the rail span collapse voltage source is as follows:

$V_{nominal}$ - The nominal voltage of the voltage source under normal conditions

V_{limit} - The voltage drop when a current of exactly I_{limit} is being drawn. Must be greater than zero

I_{limit} - The maximum current draw before voltage drop occurs

k - A constant for adjusting the slope of the logistic function

IV. EXAMPLE USAGE

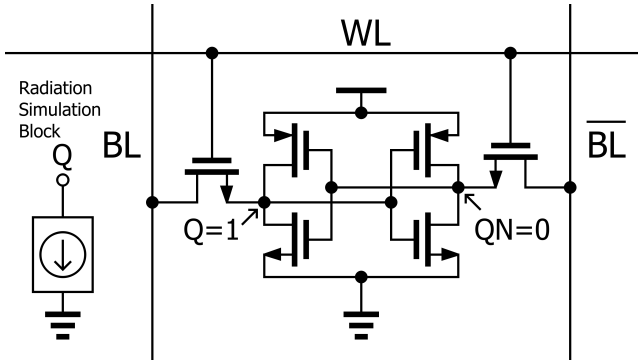


Fig. 7. Motivating Example

A. Motivating Example

In this section we will demonstrate how our simulator can be used to simulate radiation effects on a standard SRAM cell. SRAMs are susceptible to radiation induced upsets where the state of the cell can be flipped from zero to one or vice versa. To simulate a radiation strike, a schematic can be set up as seen in Fig. 7. In this schematic, a radiation simulation block is placed to simulate a particle striking the drain region of the NMOS transistor on the Q side of the SRAM. The parameters of the simulation block are set according to process parameters, as well as experimental data. When the simulation is run, the radiation simulation block will inject current at a prescribed time. The results of such a simulation are presented in Fig.8

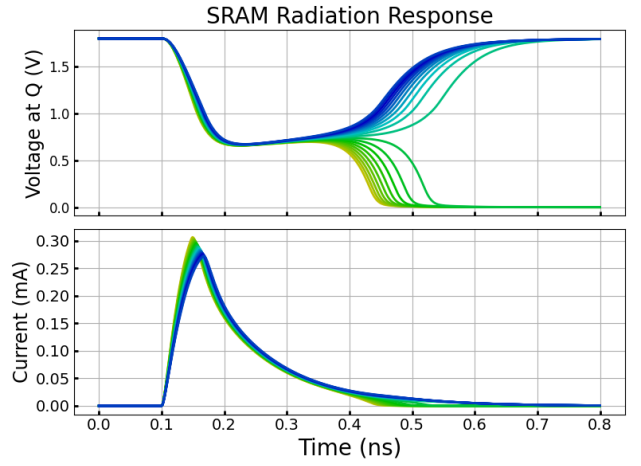


Fig. 8. motivating example result

V. CONCLUSION AND FUTURE WORK

This paper presented an open-source radiation hardening simulator designed to simulate and analyze the effects of radiation on electronic circuits. The simulator integrates XSchem and NGSpice with custom-developed modules for fault injection and radiation effect simulation. The incorporation of advanced models for Single Event Effects and Total Ionizing Dose has shown accuracy in preliminary tests, demonstrating the system's potential for reliable simulations.

In future work, we plan to further optimize the simulator and explore additional features. We aim to enhance the simulator's capability to handle more complex scenarios and to improve its user interface for better usability. Additionally, we will investigate potential collaborations with other research projects to expand the simulator's applications and impact [3]. Future developments will focus on refining the adaptive models and integrating more comprehensive radiation effect simulations to support a wider range of research and practical applications.

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